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# REVIEW

# On the chronological understanding of the homogeneous dielectric barrier discharge

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#### Abstract

Dielectric barrier discharges (DBD) are widely utilised non-equilibrium atmospheric pressure plasmas with a diverse range of applications, such as material processing, surface treatment, light sources, pollution control, and medicine. Over the course of several decades, extensive research has been dedicated to the generation of homogeneous DBD (H-DBD), focussing on understanding the transition from H-DBD to filamentary DBD and exploring strategies to create and sustain H-DBD. This paper first discusses the influence of various parameters on DBD, including gas flow, dielectric material, surface conductivity, and mesh electrode. Secondly, a chronological literature review is presented, highlighting the development of H-DBD and the associated understanding of its underlying mechanisms. This encompasses the generation of H-DBD in helium, nitrogen, and air. Lastly, the paper provides a brief overview of multiple-current-pulse (MCP) behaviours in H-DBD. The objective of this article is to provide a chronological understanding of homogeneous dielectric barrier discharge (DBD). This understanding will aid in the design of new experiments aimed at better comprehending the mechanisms behind H-DBD generation and ultimately assist in achieving large-volume H-DBD in an air environment.

# 1 | INTRODUCTION

Non-equilibrium atmospheric pressure plasma (N-APP) is a promising technology for generating high concentration reactive species at a relatively low gas temperature or room temperature [1–8], making it highly attractive for a variety of applications such as surface modification, decontamination of temperature-sensitive materials, and more [9–15]. Among the different methods used for generating N-APP, dielectric barrier discharge (DBD) is one of the most widely studied techniques and has been explored for more than a century [16–22]. In DBD, one or two dielectrics are inserted into the discharge circuit, which requires ignition of the discharge using alternating-current (AC) voltage or pulsed direct-current (DC) voltage. In addition to applying DBD for ozone generation [23–25], it has also been used for other applications including VUV sources, gas laser pumping, plasma displays, material processing, and plasma sources for medical uses [26–35]. The configuration of DBD can be broadly classified into two categories: surface DBD and volume DBD, and more

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information about these configurations can be found in references [36, 37].

It was not until 1988 when Okazaki's group reported the generation of homogeneous plasma in helium (He) mixed with diluted oxygen at atmospheric pressure that DBD had been believed to occur only in a filamentary mode, where many short (<100 ns), narrow (<100 µm) current filaments are randomly distributed in time and space over the dielectric surface [38]. Soon after, many research groups worldwide became interested in generating homogeneous DBD (H-DBD), that is, plasma is uniform in any plane parallel to the electrode surface. Among the early works, Massines's group in France improved the understanding of the H-DBD mechanisms and demonstrated its applications on surface treatment and thin film coatings [39-42]. During that period, Roth's group in the United States also proposed many possible applications of DBD [43-45]. In the subsequent decades, atmospheric pressure H-DBDs have been generated and used for other applications [32, 46-53] with the mechanisms of H-DBDs better understood.

In short, DBD has been under investigation for decades; however, numerous unanswered questions remain. One particular example pertains to the proposed theory on N<sub>2</sub> homogeneous DBD, which suggests that generating a homogeneous DBD in the air is a difficult task [54–60]. This is due to the high concentration of O<sub>2</sub>, which swiftly extinguishes the metastable state of N<sub>2</sub>, within a timeframe much shorter than the period between consecutive discharges. The objective of this article is to provide a chronological understanding of homogeneous dielectric barrier discharge (DBD). This understanding will aid in the design of new experiments aimed at better comprehending the mechanisms behind H-DBD generation and ultimately assist in achieving large-volume H-DBD in an air environment.

# 2 | EFFECT OF VARIOUS PARAMETERS ON DBD

Before delving into the effects of various parameters on DBD, there are a few points that need clarification. Firstly, it should be noted that for most H-DBD configurations, a plate-plate electrode is used. Therefore, this paper will exclusively focus on DBD with a plate-plate electrode configuration.

Secondly, from a literal standpoint, a homogeneous DBD (H-DBD) indicates that the plasma is uniform. One of the most straightforward ways to differentiate between H-DBD and filamentary DBD (F-DBD) is to take photographs of the plasma. However, since most DBD is driven by kHz power supplies, and each discharge pulse lasts from tens of nanoseconds to tens of microseconds, photographs taken with regular commercial cameras may appear homogeneous due to the integration of many filamentary discharges. Therefore, to confirm whether a discharge is homogeneous or filamentary, high-speed intensified charge coupled device (ICCD) cameras are necessary. Early studies have suggested that a discharge is homogeneous if there is only a single current pulse per half cycle. However, in the case of an arc or spark discharge, a large current pulse does not prove the H-DBD, and high-speed photographs have shown that the plasma is in fact F-DBD [61].

Thirdly, H-DBD has two distinct modes: the Townsend DBD (T-DBD) and the glow-like DBD (G-DBD). In T-DBD, the luminous regime is next to the anode, while in G-DBD, a luminous region is next to the cathode. If the gap is large enough, a positive column can also be observed [39–42]. More details on the differences between T-DBD and G-DBD will be discussed later in the paper.

Lastly, in the following sections, we will discuss the effects of gas flow, dielectric material properties, surface conductivities, and electrode shape on the appearance of DBD.

#### 2.1 | Effect of gas flow

In 2001, Gherardi and Massines [62] conducted a study on  $N_2$  discharge in a 1 mm gap. They varied the  $N_2$  flow velocity between 0 and 285 cm/s and used an AC power supply with a frequency range of 200 Hz to 20 kHz to drive the DBD. The study found that the formation of an H-DBD is primarily limited by the species etched from the surface, which act as quenchers of the  $N_2(A)$  and can cause a transition from a homogeneous to filamentary discharge. The higher the amplitude or the frequency of the applied voltage is, the more the quenchers due to the etching are, that is reason of that there is an up limit of the amplitude and the frequency of the applied voltage for H-DBD.

However, Wang's group [63] later argued in 2010 that gas flow significantly decreases the density of  $N_2(A)$  quenchers, particularly  $O_2$  etching from the dielectric, resulting in a much higher  $N_2(A)$  flux to the dielectric and release of trapped electrons on the surface. This process ultimately leads to the generation of H-DBD. Gherardi and Massines [62] believed that seed electrons were created within the gap through Penning ionisation between two  $N_2$  metastables.

# 2.2 | Effect of dielectric material

The effect of dielectric material on the discharge mode of  $N_2$  discharge was also conducted by Gheradi and Massines in 2001 [62]. They compared the discharge properties of an 8 µm thick polypropylene film deposited on both 635 µm thick Al<sub>2</sub>O<sub>3</sub> plates to that of Al<sub>2</sub>O<sub>3</sub> plates alone. Their results show that the H etching from polypropylene surfaces are more efficient in quenching N<sub>2</sub> metastables than those from alumina surfaces, which mainly consisted of O.

In 2008, Li et al. [64] studied the effect of different dielectric materials on DBD at reduced pressure air plasma. They used polytetrafluoroethylene (PTFE), quartz, and Al<sub>2</sub>O<sub>3</sub> as dielectric plates and found that the pressure range for generating H-DBD was wider when using PTFE as the barrier. According to the surface charge measurement as shown in Figure 1, it can be seen that the trapped surface charge is the highest and decays slowest for PTFE. In addition, the thermal stimulated current (TSC) measurement results presented in Figure 2 show that the integration of TSC over temperature is also the highest for PTFE, and its trap centre is 0.37 eV. All these indicate that the high concentration of surface charge is trapped in the shallow trap,

which could provide a high concentration of seed electrons for homogeneous discharge. Again, also in 2008, Li et al. [65] used a corona discharge plasma to silicone rubber plates for different treatment times, it was found that the longer the treatment time, the higher the physical defects and the chemical defects observed by scanning electron microscopy and Fourier transform infrared spectroscopy methods. By using these corona discharge rubber plates in DBD, it is found that H-DBD can be obtained in a wider pressure range when the rubber plate has higher physical and chemical defects.

In 2018, Zhang's group [66] compared the discharges of  $Al_2O_3$  and AlN dielectric plates using He/O<sub>2</sub> (0.2%–1%) as the working gas, a 2 mm gap distance, and a 20 kHz AC power supply to drive the plasma. They found that H-DBD could be obtained under certain ranges of applied voltage and O<sub>2</sub> percentage when using AlN as the dielectric. To understand the mechanism behind, the surface potential decay of the Al<sub>2</sub>O<sub>3</sub> and



**FIGURE 1** The results of the surface charge measurement. 2.5 mm air needle-plane geometry gap with a negative voltage of 5 kV corona discharge for 10 s [64].



**FIGURE 2** The results of thermally stimulated current measurement. The initial temperature was lowered to 200 K [64].

AlN plate is measured, which is related to the surface residual charge deposited on the dielectric surface. It is found that the potential of AlN dielectric decays much slower. According to the energy distribution of the electron traps, the electron traps of AlN dielectric mainly distribute at the energy level of 0.92–1.02 eV, which is higher than that of Al<sub>2</sub>O<sub>3</sub>. Besides, the peak value of the trap density of AlN is also higher than that of Al<sub>2</sub>O<sub>3</sub>. This was believed to be the reason of obtaining H-DBD when AlN is used. However, how the trapped electrons are released was not discussed by the authors.

In another study in 2018, Ran et al. [21] investigated the effect of surface roughness on H-DBD. They found that using an Al<sub>2</sub>O<sub>3</sub> dielectric with a surface roughness ( $R_a$ ) of 288 nm and a thickness of 2 mm with a 1 kHz AC power supply could generate H-DBD in a 3 mm air gap. However, when the surface roughness was 100 nm or lower, the plasma was always filamentary even at a 1 mm air gap. This was attributed to the fact that rougher surfaces had more shallow traps to trap more seed electrons, and the higher local electric field enhancement reduced the breakdown electric field strength, making it easier to generate H-DBD. So H-DBD can be obtained when the roughness of the surface is higher.

# 2.3 | Effect of surface conductivity

In 2008, Naude and Massines [67] conducted a study on the homogeneity of a 3 mm gap DBD in argon (Ar) mixed with a few hundred ppm (part per million) of ammonia. Their experimental setup involved using a silicon wafer with a conductivity of 1  $\Omega$ ·cm to cover one of the dielectric surfaces. The results showed that when the silicon wafer served as the anode, the plasma exhibited homogeneous discharge. However, when it was used as the cathode, filamentary discharge was observed. The authors attributed this phenomenon to the difference in surface conductivity. When the surface had low conductivity, a microdischarge caused a significant decrease in the gap voltage where the microdischarge appeared because the charges only deposit locally on a small area. So the deposited charges will induce a high reverse electric field. Conversely, when the surface had high conductivity, the charges spread over the entire substrate surface, leading to a small local electric field induced by the discharge that could not stop the microdischarge.

# 2.4 | Effect of mesh electrode

In 1993, Okazaki et al. [68] proposed the use of a fine metal wire mesh (diameter 0.035 mm) as an electrode and a polyethylene terephthalate (PET) plate as the dielectric. This setup was found to generate a homogeneous discharge in Ar, air, or  $N_2$  at a gap distance of a few millimetres, using a 50 Hz AC voltage.

In 1998, Trunec et al. [69] also investigated the effect of the mesh electrode on He, Ar, and  $N_2$  discharge in a 1.5 mm discharge gap using a 50 Hz AC power supply. They found that at a relatively low applied voltage, a homogeneous discharge could be obtained for all three types of gases. To better

understand the effect of the mesh electrode, they calculated the electric field distribution in the gap and found that the addition of mesh did not affect the electric field in the discharge. Furthermore, they estimated the resistance of the mesh to be about 0.5  $\Omega$ . They concluded that this resistance might prevent micro-discharge, resulting in the generation of H-DBD.

In 2006, Wang et al. [70] reported a homogeneous air DBD with a gap distance of 2 mm by using a mesh electrode with a wire diameter of 0.03 mm placed on a 0.1 mm thickness PET plate driven by a 50 Hz AC power supply. They calculated the electric field along the axis with an applied voltage of 6.6 kV, as shown in Figure 3. The results showed that the electric field next to the PET film was enhanced when a mesh electrode was used. This enhanced electric field could initiate corona discharge and provide seed electrons, which was proposed as the reason for generating H-DBD. It should be noted that reported by Trunec et al. [69], 1 mm Al<sub>2</sub>O<sub>3</sub> was used, which is 10 times thicker than what was used by Wang et al. [70]. Although the dielectric constant of Al<sub>2</sub>O<sub>3</sub> is about 9–10, which is larger than that of PET film of 3.8. But the PET film used by Wang et al. [70] is 10 times thinner than  $Al_2O_3$  sheet used by Trunec et al. [69]. This may be the reason why Trunec et al. [69] did not observe electric field distortion in the gap by the mesh electrode.

# 3 | CHRONOLOGICAL UNDERSTANDING OF THE MECHANISM OF H-DBD

# 3.1 | He H-DBD

(1) Basic three conditions hypothesis

In 1990, Okazaki's group [71] proposed a set of rules for obtaining homogeneous DBD, which comprised three



**FIGURE 3** The electric field in a 2 mm air gap. Z = 0 and Z = 0.1 mm is the electrode-PET interface and PET-air gap interface, respectively. Applied voltage 6.6 kV, frequency 50 Hz AC [70].

conditions. The first condition required the use of helium (He) as the dilute gas, which was believed to have highenergy metastable states (around 20 eV) that could ionise trace amounts of air in the gap, thus providing a longer glowarc transition time. The second condition required the use of a high-frequency source, such as kHz or RF, although the authors did not provide a reason for this. They only described that atmospheric G-DBD was obtained in an 8 mm gap with He as the working gas and a 3 kHz power supply. The third condition involved covering at least one of the electrodes with a dielectric plate, which was attributed to the charge build-up on the dielectric plate resulting in an opposite voltage that would stop the discharge. The authors also obtained the cathode fall of the plasma based on the relation between the voltage and gap distance and confirmed that the plasma was G-DBD. However, the rules did not include a gap distance requirement, and the plasma could transition to F-DBD when the gap distance exceeded 8 mm. The same group also generated H-DBD in an Ar/NH3 mixture [72]. NH<sub>3</sub> was added to Ar because the metastable state of Ar has an energy higher than the ionisation potential of NH<sub>3</sub>. The use of Ar or other gases without He could also achieve H-DBD when the applied voltage frequency is sufficiently high. Therefore, the conditions for the generation of H-DBD need to be reevaluated.

#### (2) Advanced three conditions hypothesis

In 1998, Massines and colleagues [39] investigated a 5 mm gap dielectric barrier discharge (DBD) driven by a 10 kHz AC power supply with He as the working gas. Their results showed that between two consecutive discharges, the current is not equal to 0, and there is a small "residual current peak" when the gas voltage reverses, which decreases with a decrease in the frequency of the applied voltage to lower than 5 kHz or when trace amounts of air are present. To understand this observation, they carried out one-dimensional modelling and added 0.5% N<sub>2</sub> to He to mimic the roles of He impurities. Their simulation successfully reproduced the current behaviour between two consecutive discharges as shown in Figure 4. The simulated spatial and temporal resolved electron density distribution showed that when the polarity of the gap voltage changes, the electrons move to the new anode, which is related to the current peak around the time when the polarity of the gas voltage changes.

The plasma generated by the discharge was also captured by a high-speed ICCD camera and reported for the first time, as shown in Figure 5 [39]. It clearly indicates that the discharge is a glow DBD. This was also confirmed by their onedimensional simulation, where the cathode fall, negative glow, Faraday dark space, and positive column region can be clearly seen.

Based on their observation, they proposed the following three-condition hypothesis for the generation of atmospheric pressure H-DBD. Firstly, the breakdown electric field  $E_{bd}$  must be low to control the avalanche amplification and avoid it from

growing too fast. This can be achieved by having Penning ionisation as the main path of electron creation, which leads to an increase in the ionisation coefficient at low electric field. Secondly, the residual electron density in the gas before the ignition of a new discharge must be high enough, which is linked to the amplitude of the reverse current peak. They assumed that an electron density of at least  $10^6-10^7/\text{cm}^3$  is needed for H-DBD. This is the reason why the plasma transits to filamentary when the frequency of the applied voltage is too low because the residual electron density decays with time. Thirdly, the electrons trapped in the shallow traps of the dielectric surface during the previous current pulse also play an important role in obtaining an H-DBD.

To determine if Penning ionisation  $He(2^{3}S) + N_{2} \rightarrow N_{2}^{+}(B) + He + e$  can contribute enough ionisation, they compared the simulation on the direct ionisation (electron collision ionisation) and Penning ionisation, as shown in Figure 6 [73]. The two ionisation paths were found to be comparable.

Additionally, it should be noted that the  $He(2^{3}S)$  contributed to the Penning ionisation is generated during the current pulse rather than from the previous pulse. This is because the lifetime of  $He(2^{3}S)$  is shorter than the pulse period as can be seen from the following reactions,

$$\operatorname{He}(2^{3}\mathrm{S}) + \operatorname{He} \to 2\operatorname{He} + h\nu,$$
 (1)

$$\operatorname{He}(2^{3}S) + 2\operatorname{He} \rightarrow \operatorname{He}_{2} + \operatorname{He},$$
 (2)

$$\operatorname{He}(2^{3}S) + e \rightarrow \operatorname{He} + e,$$
 (3)

where the reaction rate coefficients are  $k_1 = 6.0 \times 10^{-15} \text{ cm}^3 \text{s}^{-1}$ ,  $k_2 = 2.5 \times 10^{-34} \text{ cm}^6 \text{s}^{-1}$ , and  $k_3 = 2.9 \times 10^{-9} \text{ cm}^3 \text{s}^{-1}$ , respectively [74–82]. The lifetime of He(2<sup>3</sup>S) was estimated to be on the order of tens of  $\mu$ s, when a trace amount of N<sub>2</sub> or O<sub>2</sub> is presented. The lifetime of He(2<sup>3</sup>S) could be even shorter. For example, when 1% of N<sub>2</sub> is presented, He (2<sup>3</sup>S) + N<sub>2</sub>-> He + N<sub>2</sub><sup>+</sup> + e. This reaction has a reaction coefficient of 5 × 10<sup>-17</sup> m<sup>3</sup>/s. So He(2<sup>3</sup>S) has a lifetime of about 1  $\mu$ s under such conditions.

Finally, the simulation on the electric field, ion density, and electron density spatial distribution by Massines et al., as shown in Figure 7, clearly shows that the plasma is a glow discharge, where the electric field next to the cathodes is high, corresponding to the cathode fall.





**FIGURE 4** Time variation over one cycle of the low values of the calculated discharge current, and of the gas voltage. Gap distance: 5 mm. Working gas: He (99.5) + Ar (0.5%) [39].



**FIGURE 5** 10 ns exposure time photograph of the 5 mm gap taken when the discharge current is maximum. The cathode is located at the bottom. Gap distance: 5 mm. Working gas: He [39].

**FIGURE 6** Calculated source terms of direct and Penning ionisation in an He H-DBD [73].



**FIGURE 7** Spatial evolution of the electric field, the ion, and the electron densities at the time when the discharge current is maximum. Gap distance 5 mm, working gas He. The cathode is on the right-hand side and the anode on the left [39].

# 3.2 | $N_2$ H-DBD

#### (1) N<sub>2</sub> metastable Penning ionisation hypothesis

In 2000, Massines et al. [77] conducted a study on the behaviour of atmospheric pressure  $N_2$  discharge with gap distances of a few mm. The results showed that as the dissipated power increased, a transition from homogeneous to filamentary mode was always observed. However, the minimum power required for this transition varied depending on the nature of the dielectric surface. This variation was attributed to the quenching rate of  $N_2(A)$  by H, which was found to be about 10 times higher than that of O. The etching product of  $Al_2O_3$  plate was mainly O, while that of polymer film was mainly H, allowing the former to operate in a homogeneous mode at high power and the latter only at low power.

Furthermore, the power deposited in an F-DBD was found to be greater than that of H-DBD, but the emission of NO<sub> $\gamma$ </sub> was much lower, and ON<sub>2</sub> was not even observed in F-DBD. The temporal emission behaviour of NO<sub> $\gamma$ </sub>, N<sub>2</sub>, ON<sub>2</sub>, and the discharge current as shown in Figure 8 suggested that NO $\gamma$  was not excited by electrons (reaction 4) but by long lifetime, highenergy species, that is, N<sub>2</sub>(A) through reaction (5). Similarly, ON<sub>2</sub> was generated through reactions (6) and (7), which also required the participation of N<sub>2</sub>(A). Therefore, the concentration of N<sub>2</sub>(A) was significantly reduced in F-DBD [77].

Based on the above discussion, it was concluded that the H-DBD generated in  $N_2$  was due to the high concentration of seed electrons generated through Penning ionisation between two  $N_2$  metastable molecules via reactions (8) and (9).

$$\operatorname{NO}\left(X^{2}\prod_{r}\right) + e \to \operatorname{NO}\left(A^{2}\sum^{+}\right) + e,$$
 (4)



**FIGURE 8** Time variation during a half-cycle of the discharge current  $(I_d)$  and the amplitude of the emission bands. The maximum of the current and the emission are normalised to 100, and the exposure time of each spectrum is 10 ns. The gas gap is 2 mm and the applied voltage has a peak of 8 kV [77].

$$NO(X^{2}\Pi_{r}) + N_{2}\left(A^{3}\Sigma_{u}^{+}\right) \rightarrow NO\left(A^{2}\Sigma^{+}\right) + N_{2}\left(X^{1}\Sigma_{g}^{+}\right)$$

$$(5)$$

ľ

$$O(^{3}P) + N_{2}\left(A^{3}\sum_{u}^{+}\right) \rightarrow O(^{1}S) + N_{2}\left(X^{1}\sum_{g}^{+}\right), \quad (6)$$

$$O(^{1}S) + N_{2}\left(X^{1}\sum_{g}^{+}\right) + N_{2} \rightarrow O(^{1}S)N_{2} + N_{2}, \quad (7)$$

$$N_2(a'^{-1}\sum_{u}^{-}) + N_2(A^{-3}\sum_{u}^{+}) \to N_4^+ + e,$$
 (8)

$$N_2(a^{'1}\sum_{u}^{-}) + N_2(a^{'1}\sum_{u}^{-}) \to N_4^+ + e$$
 (9)

The respective reaction rates are  $k_4 = 2.0 \times 10^{-10} \text{cm}^3 \text{s}^{-1}$  [83],  $k_5 = 6.6 \times 10^{-11} \text{cm}^3 \text{s}^{-1}$  [79],  $k_6 = 2.1 \times 10^{-11} \text{cm}^3 \text{s}^{-1}$  [80],  $k_7 = 4 \times 10^{-18} \text{cm}^3 \text{s}^{-1}$  [81],  $k_8 = 5 \times 10^{-11} \text{ cm}^3 \text{s}^{-1}$  [82], and  $k_9 = 2 \times 10^{-10} \text{ cm}^3 \text{s}^{-1}$  [82].

(2)  $N_2(A) + e_{trapped} \rightarrow N_2 + e$  hypothesis

Then few years later, in 2003, Massines's group [73] acknowledged that Penning ionisation between two metastable states (reaction 8 and 9) cannot contribute to the seed electrons required for H-DBD due to the short lifetime of  $N_2(a)$ . In an effort to confirm this, they added Xe to  $N_2$ , since Xe is an efficient quencher of  $N_2(a)$  but not  $N_2(A)$  [61]. Their findings indicated that H-DBD could still be obtained, thus supporting the notion that  $N_2(a)$  does not play a significant role in the generation of H-DBD.

As a result, the group proposed that the  $N_2(A)$  flux to the dielectric surface, which significantly increases the cathode secondary emission coefficient  $\gamma$ , is responsible for the H-DBD. This is illustrated in Figure 9, which depicts the group's simulation results showing that the  $N_2(A)$  flux to the dielectric surface is comparable to the ion flux. It is therefore assumed that  $N_2(A)$  generates seed electrons by removing the trapped electrons trapped in the shallow trap during the previous discharge.

Besides, their simulation results on the electric field, ion density, and electron density spatial distribution as shown in Figure 10 clearly show that the plasma is Townsend discharge, where it's electric field along the discharge is more or less uniform.

When  $Al_2O_3$  was used as the dielectric, the quencher  $O_2$  was believed to result from the etching of the dielectric surface. To better know the effect of  $O_2$  on the transition of H-DBD to F-DBD, in 2005, Kozlov et al. [82] investigated the effect of trace amounts of  $O_2$  on  $N_2$  DBD driven at 6.5 kHz in a gap of approximately 1 mm. It was found that the plasma appeared as



**FIGURE 9** Discharge current,  $N_4^+$  and  $N_2(A)$  metastable fluxes on one of the dielectric surface as a function of time during a cycle in a H-DBD in  $N_2$ . The considered dielectric is on the anode during the first current peak and on the cathode during the second one [73].



**FIGURE 10** Calculated space distribution from the anode to the cathode of the electrical field, the ion and electron densities in a  $N_2$  H-DBD when the discharge current intensity is maximum. Gap distance 1 mm [73].

a Townsend discharge when the  $O_2$  concentration was below 500 ppm. However, when the  $O_2$  concentration exceeded 1000 ppm, the discharge appeared in an F-DBD mode. This was attributed to the much more effective quenching of  $N_2(A)$ by  $O_2$ , as can be seen from reactions (10) and (11). Brandenburg et al. [83] reported similar findings in the same year, noting that the H-DBD to F-DBD transition occurred at around 450 ppm  $O_2$ .

$$N_2(A) + N_2 \rightarrow N_2(X) + N_2,$$
 (10)

$$N_2(A) + O_2 \rightarrow N_2(X) + O_2(a, b),$$
 (11)

where  $k_{10} = 3 \times 10^{-18} \text{ cm}^3 \text{s}^{-1}$  and  $k_{11} = 2.54 \times 10^{-12} \text{ cm}^3 \text{s}^{-1}$ .

However, Kozlov et al. [82] observed a significant increase in  $N_2$  second positive system emission when the  $O_2$  concentration was increased from 0 to 40 ppm, as shown in Figure 11.



**FIGURE 11** Transition between the filamentary and diffuse modes. Behaviour of the integral radiation intensities for selected species. Gap distance 1 mm, applied voltage 19 kV, frequency 6.5 kHz AC [82].

This observation cannot be explained by the current knowledge of DBD in  $N_2$  and will be further discussed in the next section.

To better know the effect of  $N_2(A)$  on DBD behaviour, in 2007, Dilecce et al. [83] reported the first temporal and spatial resolved measurement of  $N_2(A)$  concentration in a  $N_2$  with small  $O_2$  admixture discharge by LIF. In their experiment, a trace amount of  $O_2$  is added to the main working gas  $N_2$ . The gap distance is 1.4 mm, and the frequency of the applied voltage is 1.79 kHz. It was found that the H-DBD to F-DBD transition starts at 250 ppm  $O_2$ , but the  $N_2(A)$  concentration during the discharge current pulse does not decrease dramatically when 250 ppm  $O_2$  is added. The  $N_2(A)$  concentration is on the order of  $10^{13}$ /cm<sup>3</sup>. However, the  $N_2(A)$  decays much faster when  $O_2$  is added due to the much higher quenching rate of  $O_2$ , O, and NO as shown in reactions (11)–(13).

$$N_2(A) + O \rightarrow N_2(X) + O({}^1S),$$
 (12)

$$N_2(A) + NO \rightarrow N_2(X) + NO,$$
 (13)

where the reaction rate of Equations (12) and (13) are  $k_{12} = 2.1 \times 10^{-11} \text{ cm}^3 \text{s}^{-1}$  and  $k_{13} = 7 \times 10^{-11} \text{ cm}^3 \text{s}^{-1}$ , respectively.

# (3) $N(P) + O(P) \rightarrow NO^+ + e$ hypothesis

As previously mentioned, Brandenburg et al. [84] reported an increase in plasma stability and N<sub>2</sub> second positive system emission when very low concentrations of O<sub>2</sub> (up to 40 ppm) were added, which could not be explained by current theory. To better understand this phenomenon, Tyl et al. [85] designed a specialised experiment setup. In their electrode configuration, the ground electrode was divided into eight disconnected strips (3.4 mm × 30 mm) with a 400  $\mu$ m distance between nearby strips, and each strip was connected to a 1.7 k $\Omega$  resistor. The typical current and voltage waveform of the plasma is shown in Figure 12. It is evident that there is a current component that changes sign immediately when the gas voltage polarity reverses. This was attributed to electrons continuously produced between two discharges because ions are heavy and the electric field is low, which cannot respond to the change of voltage polarity so quickly.

The evolution of the current jump (the sudden increase of the current when the voltage switch polarity) as a function of position for various  $O_2$  concentrations is illustrated in Figure 13. The current jump increases significantly when 25 ppm  $O_2$  is added, as evident from the plot. Further increase in  $O_2$  concentration results in a decrease of the current jump, but it remains higher than the case of pure  $N_2$  until the  $O_2$ concentration reaches approximately 200 ppm. Subsequently, the current jump becomes lower than that of pure  $N_2$ , when 450 ppm  $O_2$  is added, and a further increase in  $O_2$  concentration, the transition to F-DBD occurs.

Figure 14 presents the optical emissions of  $N_2$  Herman Infrared (N<sub>2</sub>-HIR) system, NO $\gamma$ , O(<sup>1</sup>S)N<sub>2</sub>, power deposited, and current jump as a function of O<sub>2</sub> concentration at the gas output (on the eighth strip). The N<sub>2</sub>-HIR is due to reaction (14), while NO $\gamma$  and O(<sup>1</sup>S)N<sub>2</sub> are related to reactions (5)–(7). The decrease of N<sub>2</sub>-HIR with an increase in O<sub>2</sub>



 $FIGURE\ 12$  Oscillogram of a DBD in  $N_2$  with 25 ppm  $O_2$  (3 kHz, 11.6 kVpp, 1 mm) [85].



**FIGURE 13** Current jump evolution as a function of the position in  $N_2$  DBD with different concentration of  $O_2$  (3 kHz, 12 kV<sub>pp</sub>, 1 mm) [85].

concentration was attributed to the quenching of  $N_2(A)$  by  $O_2$ . The current jump's increase when  $O_2$  is increased from 0 to 50 ppm cannot be explained solely by  $N_2(A)$  since  $N_2(A)$  concentration actually decreases. Finally, it was proposed that the associative ionisation reaction between  $N(^2P)$  and  $O(^3P)$  is responsible for the current jump, as indicated by reaction (15), which is closely related to H-DBD, based on the increase in  $O(^1S)N_2$  emission, which is related to  $O(^3P)$  as can be seen from (5)–(7).

$$N_2(A) + N_2(A) \rightarrow N_2(C'') + N_2(X),$$
 (14)

$$N(^{2}P) + O(^{3}P) \rightarrow NO^{+} + e$$
 (15)

#### 3.3 | Ion trapping hypothesis

In 2005, Roth et al. [86] proposed the ion trapping mechanism for generating atmospheric pressure H-DBD. According to this mechanism, H-DBD can be obtained when the gap distance, electric field, and frequency are adjusted such that ions are trapped between the electrodes during an AC cycle, while electrons are free to travel to the electrodes. The frequency  $f_0$ of the applied voltage should lie between certain limits given by Equation (14),

$$\frac{\mathrm{e}U_{\mathrm{rms}}}{\pi m_{\mathrm{i}} v_{\mathrm{ci}} d^{2}} \leq f_{0} \leq \frac{\mathrm{e}U_{\mathrm{rms}}}{\pi m_{\mathrm{e}} v_{\mathrm{ce}} d^{2}} \, [\mathrm{Hz}] \tag{16}$$

where  $U_{\rm rms}$  is the applied voltage, d is the gap distance, and  $m_{\rm e}$  and  $m_{\rm i}$  are the mass of the electron and ion, respectively.

In 2009, Massines et al. [61] pointed out that the ion density near the cathode in G-DBD is on the order of  $10^{9/}$  cm<sup>3</sup>, and its flux at the cathode is on the order of  $10^{13}/(\text{cm}^2 \cdot \text{s})$ , as seen in Figure 7. This could result in a significant emission of electrons from the cathode. However, the ion density decreases with time, so if the excitation frequency is too low



**FIGURE 14** Correlation between the current jump, the surface power and N<sub>2</sub>-HIR, NO<sub> $\gamma$ </sub>, O(<sup>1</sup>S)N<sub>2</sub> emissions as a function of O<sub>2</sub> concentration, at the gas output on the eighth zone (3 kHz, 12 kV<sub>pp</sub>, 1 mm) [85].

(typically <1 kHz), such a mechanism is not fulfilled. Besides, in T-DBD, there is no positive column, and the electric field in the gap is much higher, as shown in Figure 10. Ions drift to the cathode at a timescale of microseconds, and thus they do not contribute to H-DBD.

# 3.4 | Air H-DBD

For the low operation cost, air (mainly composed of nitrogen and oxygen) is considered as the most desirable working gas for industrial applications as shown in Figure 15. However, different from DBD in nitrogen, the nitrogen metastable species in air discharge would be efficiently quenched and electrons would also be easily attached to electronegative gases, such as oxygen and water vapour, which induces DBD in air usually in filamentary mode at atmospheric pressure. Therefore, after Okazaki's group first reported generating H-DBD in He in 1988 [38], it takes a few more years for them to report a H-DBD in air in 1993, which was generated by a 50 Hz AC voltage at gap distance of few mm with 0.035 mm diameter fine metal wire mesh electrode and a polyethylene terephthalate (PET) plate as the dielectric [68]. Inspired by the achievement of Okazaki's group, more researchers obtained H-DBD using mesh electrodes and electret materials [87-89]. With the development and application of pulsed power supplies for discharge excitation, short pulses exhibit the advantages in generating H-DBD in air [90-93].

#### (1) Electrode structure

Since Okazaki's group realised H-DBD in air by utilising mesh electrode and PET plate in 1993, Tepper et al. [87] and

Fang et al. [88] realised H-DBD in nitrogen and air with the electret film and mesh electrode structure. The uniformity of the discharge with the mesh electrode covered by PET film was also first observed by ICCD with 100 ns exposure time. Fang et al. [94] investigated the factors, including voltage amplitude, gap distance, electrode configuration and barrier thickness, influencing the H-DBD in air and concluded that the important role of the wire mesh to provide initial electrons by producing corona discharge. Buchta et al. [89] proposed that the high resistance of the mesh electrode could inhibit the transition from uniform discharge to filamentary discharge. Golubovskii et al. [95] investigated the function of PET film in H-DBD by performing a two-dimensional fluid simulation and found the PET film as electret material could maintain the charge for a long time from the last discharge to the successive discharge as seed electrons. In 2013, Shao et al. [96] compared the metal electrode and water electrode air DBD as shown in Figure 15. For the metal electrode, the experimental results showed that the discharge was uniform at the 1 mm gap, and when the gap increased to 4 mm, the discharge changed into a filament mode. The discharge of water electrode always presented a uniform pattern. The water electrode could be regarded as a resistance in series with the discharge circuit. It acted as a distributed ballast to limit the discharge current, which also resulted in a lower rotating temperature of the water electrode compared with the metal electrode, thus avoiding the transition from glow to filament. In 2017, Liu et al. [97] proposed a line-plane electrode with floating voltage electrode, which was composed of high-voltage electrode, floating voltage electrode, air gap, barrier medium, and metal electrode. The research on the electric field of the line-plane electrode with floating voltage electrode showed that the strong electric field regions that were conducive to the initial discharge were



FIGURE 15 DBD experimental device (a) water electrode air DBD [96]; (b) floating voltage electrode DBD [97]; (c) multilayer DBD [98]; and (d) curved plate electrode DBD [99].

formed near the contact point between the high voltage electrode and the floating voltage electrode, and these regions could provide enough and uniformly distributed initial electrons for the air gap with relatively uniform and low electric fields. Therefore, the filament discharge could be suppressed. In 2018, Li et al. [98] reported a multilayer DBD structure driven by submicrosecond pulsed power for H-DBD in air generation. The H-DBD could be generated with different gas gaps and different thicknesses of dielectric. And the discharge uniformity is mainly determined by the distance of the larger gap. With more than 4 mm gas gap, the discharge stayed in a filamentary mode. In 2021, Cui et al. [99] realised the enhanced Townsend discharge in air with a curved plate electrode. Due to low discharge voltage and weak filament discharge intensity, the number of spikes in the current waveform of uneven plate electrode was reduced, and the spikes in the current waveform of curved plate electrode were almost eliminated. A certain degree of non-uniform electric field distribution could control the development of electron avalanche and adjust the transition from electron avalanche to streamer with non-uniform electric field distribution.

#### (2) Dielectric material

The dielectric material can affect the discharge mode by its surface characteristics and electric properties. Besides electret material, Osawa et al. [100] found that porous alumina ceramic played an important role in generating stable Townsend discharge. The "shallow trap" effect on the surface of alumina ceramics provides additional seed electrons and forms a uniform discharge in the air. Ran et al. [21, 101] studied the influence of dielectric surface morphology on discharge mode using different dielectric materials with similar equivalent capacitance and barrier media with surface morphology as shown in Figure 16. The results showed that the surface morphology of the dielectric materials played an important role in the discharge mode. With the quartz glass surface roughness increasing, the filaments decreased correspondingly. With a suitable surface roughness of alumina ceramic ( $R_a = 203$  nm), the H-DBD in air could be obtained. Zhang et al. [102] found

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the emission intensity of N<sub>2</sub> ( $C^3\Pi_u \rightarrow B^3\Pi_e$ , 0-0, 337.1 nm) was almost proportional to the dielectric constant of the material, and the seed electrons required for uniform discharge could be generated by depositing absorbed electrons in shallow wells with energy levels lower than 1 eV. It would be easy to obtain uniform discharge using low dielectric constant dielectric plates. Belinger et al. [58] investigated the influence of the dielectric thickness on the homogeneity of H-DBD in air, which was related with the dielectric capacitance, and concluded that the H-DBD resulted from the control of the current density by the means of the dielectric capacitance.

#### (3) Power supply

Around 2000, most researchers powered DBD with 50 Hz power frequency AC power supply [68, 88, 103]. After 2010, high-frequency (such as 50 kHz) AC or pulsed power supplies became more popular power sources for generating H-DBD due to their identified advantages in applications [90, 93, 104]. Yang et al. [93] demonstrated the generation of H-DBD in nitrogen for an interelectrode gap distance of 4.5 mm and in air for a gap distance of 3.5 mm using a bipolar nanosecond pulsed voltage with 20 ns rise time. The gas temperature was found to be increasing with the gas-gap distance but almost constant with the pulse voltage (from 22 to 30 kV) or pulse repetition rate (from 90 to 210 Hz). Wang et al. [104] compared the discharge uniformity, power deposition, energy efficiency, and operation temperature between a coaxial DBD reactor driven by AC and nanosecond pulsed voltages. As shown in Figure 17a, the nanosecond pulsed coaxial DBD has a better discharge uniformity, a much higher instantaneous power deposition, and a higher energy efficiency with lower operation temperature. Jiang et al. [90] compared the DBDs generated by 40-kHz AC and 70-ns duration, 40-ns rise time nanosecond pulsed power supplies, as shown in Figure 17b. The comparative images indicate that the nanosecond-pulsed DBD behaves in a homogeneous mode, whereas the AC DBD consists of distributed filaments.

#### (4) Mechanisms for air H-DBD



FIGURE 16 (a) Waveforms of the applied voltage  $V_{a}$ , current I, AFM scan of ceramics and (b) the discharge images (500 ms for smooth ceramics, 500 ms and 10 ns for rough ceramics) in 2-mm air at atmospheric pressure, smooth ceramics with average roughness  $R_a = 64$  nm, surface area  $S_a = 404 \,\mu\text{m}^2$ , ceramics with  $R_a = 203$  nm,  $S_a = 455 \ \mu m^2$  [101].

From the above investigations, it can be seen that different electrode structures, dielectric barrier materials, and power supplies can affect the discharge process, which results in air DBD with different characteristics and in different modes. At atmospheric pressure, it is more likely to form a filamentary discharge due to the high collisional frequencies and ionisation rates. To control the electron avalanche amplification, it is important to reduce the ionisation coefficient, which increases with the reduced electric field strength. Formation of H-DBD at atmospheric pressure hence needs to be in a low electric field strength and a relatively uniform distribution of the space charge between the interelectrode gaps to avoid electric field distortion. However, in air, due to the quenching of the nitrogen metastable  $N_2(A)$  by  $O_2$ , Penning ionisation cannot be used for the electron creation to maintain discharge at a low electric field. Consequently, specific electrode structures such as mesh electrodes [68, 87-89] and asymmetric electrical structures with small radius components [97, 99] were designed to produce seed electrons. Some materials such as electret material [68, 87–99] and porous alumina ceramic [21, 100, 101] can also facilitate the seed electron generation in favour of the homogeneous mode. The mechanism for an electret material to generate a homogeneous discharge can be explained as the desorption current density  $j_{des}$  of the electret material (on the

order of  $10^4$ - $10^5$  cm<sup>-2</sup>s<sup>-1</sup>, that is only one electron may be emitted from an area of 1 cm<sup>2</sup> during  $10^{-4}$ - $10^{-5}$  s) is much less than that of an ordinary dielectric barrier material (on the order of  $10^{10}$ - $10^{12}$  cm<sup>-2</sup>s<sup>-1</sup>) after discharge [95, 104]. Therefore, the remaining charges in the electret material should provide seed electrons for discharge initiation so that the breakdown process can happen at a lower voltage. With large desorption current and minimal overvoltage, a homogeneous discharge can be obtained [95]. The function of the electret material in DBD is illustrated in Figure 18. It shows that after discharge, the charges are injected in electret material or deposited on the material surface in Figure 18a, which results in the discharge extinguishing but enhances the discharge in the next half circle with seed electrons and the extra electric field. Therefore, one of the mechanisms of the formation of air H-DBD is the seed electron generation by the optimisation of the electrode structure and the selection of dielectric barrier materials.

The multilayer and water electrode structure DBDs can limit current as distributed ballasts, thus lower the electric field and prevent the discharge from glow-to-filament transition [96, 98]. The application of nanosecond pulsed power excitation can also prevent the transition from glow to filament by applying steep pulse edges and short pulse durations [90, 93, 104]. Generally, the breakdown voltage of a nanosecond pulsed DBD



FIGURE 17 Images of the nanosecond-pulsed DBD and the ac DBD at different applied voltages with (a) coaxial DBD structure [104] and (b) plate-plate DBD structure [90].



FIGURE 18 Illustration of the function of electret material in DBD (a) after and (b) before discharge.

is much higher than that of an ac DBD, which results in a higher instantaneous electric field and more seed electrons in the gap. At the same time, the application of a short pulse duration prevents the gas heating and reduces the formation of the secondary avalanche and steamers. Figure 19 shows the discharge process of a nanosecond pulsed DBD at the rise and fall edges. During the rising edge of the pulse, Figure 19a shows a simplified charged particle (i.e., positive ions and electrons) motions before the first breakdown discharge occurs in the gap. Under the applied electric field, the gas is ionised, and the ionisation coefficient mainly depends on the electric field strength. Figure 19b is a snapshot of the charged particle distribution when the breakdown discharge is occurring. The electrons are accelerated to the instantaneous anode by the electric field and collide with the ambient molecules along their way, resulting in the electron avalanche. Figure 19c shows that the discharge is soon extinguished after the electron avalanche develops and extends to the entire gas gap, and the internal electric field established in the discharge cancels the external electric field, resulting in insufficient field strength to sustain the discharge. During the falling edge of the pulse, Figure 19d shows the charge distribution before the second breakdown. The residual charges on the dielectric surface and in the gap after the first discharge will affect the discharge process during the pulse falling edge. With the (sudden) decrease of the applied

voltage, the reverse electric field due to the surface charges established in the previous process is suddenly enhanced such that the electrons are accelerated towards the other electrode, resulting in the second breakdown. When the second breakdown occurs, similar as the first discharge, the ionisation happens and the electron avalanche develops, as shown in Figure 19e. Figure 19f shows that after the second discharge, the residual charge recombines and dissipates.

Homogeneous discharge in air is still rare in industries despite the efforts made in understanding the mechanisms for air H-DBD in the past decades. For nanosecond pulsed excitation, there are many parameters affecting the discharge process in a synergetic and coupled manner. The lack of the comprehensive studies on the dependence of the nanosecond pulsed DBD formation and mode transition on the related power and gas parameters prevents the application of air H-DBD for industrial uses. Nevertheless, strategies to reduce the electric field distortion, promote the seed electrons production, and lower the breakdown voltage by selecting suitable dielectric materials and power parameters can be helpful. For future industrial applications, more fundamental and systematic studies are needed. Effects of the pulse parameters including pulse rise time, pulse repetition rate and pulse duration on the air H-DBD generation need to be systematically investigated, following examples such as [4, 7]. In addition



**FIGURE 19** Illustration of the discharge processes of a nanosecond pulsed DBD at the pulse rise and fall edges. (a)–(f) Corresponding to the label of (a)–(f) in the current waveform.

to employing advanced diagnostic techniques, simulation modelling is needed for the comprehensive understanding and will expedite the optimisation process for industrial applications.

# 4 | MULTIPLE-CURRENT-PULSE (MCP) BEHAVIORS IN H-DBD

As mentioned in the previous section, the temporal waveform of atmospheric H-DBD is usually characterised by one narrow current pulse per half cycle of the applied voltage. Such discharge can be called single-current-pulse (SCP) behaviour and was even considered to be related to the homogeneity of DBD during the early study on H-DBDs. In fact, not only SCP behaviour but also multi-current-pulse (MCP) discharge per half cycle has been observed, reported, and investigated in the studies on uncovering the mechanism of H-DBD. Although the MCP discharge seldom occurs in noble gas and nitrogen, it can sometimes appear in helium. In this section, we will briefly introduce the research on MCP behaviours in H-DBD from experimental observations and numerical simulations, respectively.

# 4.1 | MCP behaviours from experiments

The early observation on the MCP behaviour in homogeneous gas discharges can date back to 1960s when Bartnikas [105] studied the discharge rate and energy loss in helium between metallic-electrodes at atmospheric pressure. Experiments show that at low frequencies (between 20 and 320 Hz) of sinusoidal voltage, the discharge can exhibit two types of mechanisms, namely spark-type and pseudo-glow, with gap-separation extending from 0.05 to 5.0 mm. When the discharge enters the region of pseudo-glow, the MCP behaviour in the presence of small pulses of diminishing magnitude can be observed by examining the voltage waveforms across the gap.

After 2000, when H-DBD attracted more attentions from a variety of fields, reports on MCP behaviours also began to appear in discharges with dielectric barrier. In 2001, Akishev et al. [106] reported the experimental phenomena of periodic current pulsations in H-DBDs in helium at small values of pd (p is gas pressure and d is discharge gap distance, below 500 torr mm) and moderate frequencies of the applied voltage (below 100 kHz). The MCP behaviour here is considered as "pulsed regime of the diffusive mode" of the discharge. A simplified one-dimensional numerical model is developed to investigate the origin of such MCP discharge. Results show that the physical nature of the observed MCPs can be explained in terms of the negative differential resistance of the cathode fall region, which occupies essentially the entire interelectrode gap in each half cycle of the applied voltage. In 2002, Mangolini et al. [107] also presented an experimental investigation on MCP discharge by revealing the radial structure of a low-frequency DBD at atmospheric pressure. From the simultaneously measured radial current distribution and

discharge light emission, it is observed that the first current pulse originates in the discharge centre and spreads radially outward, thereby causing a non-uniform surface charge distribution which further results in the second breakdown occurring at first in the discharge periphery. In 2003, Radu et al. [108] reported a similar pseudoglow or multipeak phenomenon in helium as that in Ref. [105] when they experimentally study H-DBD in different noble gases. It is observed that at somewhat lower frequency (2 kHz here) the MCP behaviour appears when the applied voltage is increased. Under the experimental conditions in Ref. [108], as many as eight current pulses per half cycle can be observed as shown in Figure 20. Moreover, in 2003, Shin and Raja [109] found that the pulse current densities decrease and the number of current pulses per half cycle increases as the frequency of the applied voltage decreases as shown in Figure 21. At the experimental conditions of their study, a single pulse at 10 kHz, two pulses at 5 kHz, and five pulses at 1 kHz are observed. They also analysed the formation mechanism of these MCP behaviours and considered them as a consequence of repeated temporally separated (not spatially separated) breakdown events in the discharge.

Considering that impurity is unavoidable in practical applications, in 2010, Martens et al. [110] experimentally investigated the influence of various levels of nitrogen impurity on the electrical performance of H-DBDs in helium at atmospheric pressure. They observed that the MCP discharge occurs when the nitrogen content increases. Specifically, a second breakdown at 3850 ppm of nitrogen and a third breakdown at 4000 ppm are recorded in their study. The key effect of the additional nitrogen is regarded to stimulate Penning ionisation, thereby facilitating volume ionisation and the consequent MCP discharge. In 2017, Bogaczyk et al. [111] also presented a thorough experimental study on the spatio-temporal characterisation of the MCP regime of diffuse DBD in helium with small nitrogen admixtures. They also observed that the number of current pulses per half cycle rises with the increase of nitrogen admixture due to the predominant role of Penning ionisation. Experimental



**FIGURE 20** Number of current pulses versus the applied voltage [108].

measurement and analysis showed that the transition from the first glow-like breakdown to the last Townsend-like breakdown is favoured by residual species from the former breakdowns which enhance the secondary electron emission during the prephase of the later breakdowns. Moreover, the surface charge measurements reveal that the consecutive breakdowns occur alternately at central and peripheral regions on the electrode surface, which is similar as the previous report in Ref. [107]. Sublet et al. [112] observe the apparition of oscillations on the discharge current in nitrogen when the pressure decreases.

# 4.2 | MCP behaviours from numerical simulations

Inspired by the experimental reports and studies on the MCP behaviour in H-DBDs, the numerical model is developed and utilised to investigate the underlying mechanism which is difficult to get through only by experimental means due to the limitation of diagnostics technique for non-equilibrium atmospheric pressure plasma. To this end, we have to employ the numerical model to simulate the cycle-by-cycle evolution of H-DBDs at different operating parameters and further reveal the in-depth mechanism by analysing the detailed spatio-temporal evolution of main state variables, such as electron density, ion density, and electric field.



**FIGURE 21** Dependence of the current densities and number of current pulses on the frequency of the applied voltage [109].

As early as in 2003, Golubovskii et al. [113] used a onedimensional fluid model to numerically investigate the spatiotemporal characteristics of the H-DBD in helium. They mainly studied two basic modes of the discharge, namely the Townsend and glow modes. In their numerical study, they found that the Townsend discharge in helium is characterised by small amplitudes of the current and meanwhile by the presence of MCPs during the half cycle. Detailed analysis shows that the MCP behaviour is provided by a lag between the production of ions and resonance atoms nearby the anode and subsequent ion-electron emission and photoemission at the cathode; the damping of the oscillation is caused by the desorption of electrons from the cathode.

In 2005 and 2006, Wang et al. [114, 115] used a similar onedimensional fluid model to study the MCP behaviour of H-DBD in helium at atmospheric pressure as shown in Figure 22. The effect of the applied voltage amplitude, frequency, as well as the dielectric layer, on the MCP discharge is specifically discussed and analysed. Simulation results show that MCP can be formed in the case of a smaller gap width due to the increase of charge density deposited on dielectric surfaces leading to the enhancement of the induced electric field. In addition, the amplitude and frequency of the applied voltage can also influence the number and the amplitude of current pulses. An interesting finding in Ref. [115] is that both Townsend and glow modes can be observed in a MCP discharge sequence, which is different from that only Townsend discharge presents MCP behaviours in Ref. [113]. In 2008, Zhang et al. [116] further conducted experimental study to verify the numerical findings in Refs. [114, 115]. They emphasised that in one MCP discharge sequence, the next current pulse is always affected by the previous current pulse and breakdown voltage of the second current pulse is usually lower than that of the first one. Moreover, the accumulated charges on the dielectric plate play an important role in promoting the discharge at the beginning and restraining it at the later stage in a MCP discharge sequence.



**FIGURE 22** Single-current-pulse discharge at 40 kHz (a) and MCP discharge at 10 kHz (b) [115].



FIGURE 23 MCP discharges at different amplitude of different applied voltages (a) 2000 V, (b) 2500 V, (c) 3000 V [117].

In 2015, Bai et al. [117] began to use two-dimensional fluid model to investigate the radial structure of the MCP discharge as shown in Figure 23. It is worth noting that one-dimensional model, for the sake of simplicity, holds the assumption that the discharge is homogeneous in radial direction; thus, it is not capable of dealing with the numerical study on the radial structure of MCP discharge. Through the two-dimensional model, Bai et al. found that the discharge current densities at different radial positions do not reach their peaks simultaneously, indicating a radial non-uniform structure for the MCP discharge. The time delay between the plasma ignitions in different positions becomes larger in the successive current pulses. It is believed that the edge effect in the first current pulse and the activation-inhibition mechanism in the successive current pulses lead to the radial non-uniformity.

From 2018, Dai's group from South China University of Technology conducted a lot of work on understanding the MCP behaviours in DDBs at atmospheric pressure. In 2018 [118], using one-dimensional fluid model, they reported a systematic investigation on the dynamics and evolution mechanism of MCP behaviour in H-DBD in helium at atmospheric pressure. Similarly, they also found that the MCP discharge can include both Townsend and glow modes. Comparing previous studies, their work revealed more details on the dynamics and evolution as the parameters (the amplitude and the frequency of the applied voltage and gap width) vary. In 2019 [119], they further used the similar onedimensional fluid model to investigate the influence of nitrogen impurity on the evolution of MCP behaviour in an H-DBD in helium. They observed that the discharge evolves from the MCP mode into a single-pulse mode, and finally returns to the MCP mode when the nitrogen content changes from 0.1 ppm to 10,000 ppm. In particular, they analysed the role of Penning ionisation in the dynamic evolution of discharge at different nitrogen content, thus providing a better understanding on the evolution of MCP discharge from the underlying reactions. In 2020 [120], Dai's group utilised the same numerical model to investigate the influence of oxygen on the MCP behaviour in an atmospheric H-DBD in helium

with air impurities. It was found that the oxygen Penning ionisation plays a leading role in the discharge characteristics. As the air content rises from 0 to 5000 ppm, the discharge undergoes a transition from a single-pulse mode to MCP mode, and the number of current pulses also increases. Further analysis also reveals that the rapid growth of direct ionisation prior to the breakdown and the attachment reaction of oxygen both help to generate the MCP discharge at higher air concentration. In 2021, Dai et al. extended their study from the discharge driven by the sinusoidal voltage to the discharge driven by repetitive unipolar narrow pulse [121]. Using the same one-dimensional fluid model, they investigate the effects of applied voltage amplitude, pulse repetition frequency, gap width, and secondary electron emission coefficient on the formation of MCP discharge. An interesting phenomenon, which is never reported in the previous work driven by the sinusoidal voltage, is that under repetitive unipolar pulse excitation, the MCP behaviour will lead to the stratification of electron density distribution in axial direction. Further analysis reveals that the increasing electric field of the cathode fall region is the basis for the formation of MCP behaviour. Based on their fundamental understanding on the formation mechanism of MCP behaviour in H-DBDs, Dai's group also tries to manipulate or control the MCP discharge to avoid the negative influence of MCP discharge in practical applications. In 2019 [122], they reported a systematic numerical study on the control of discharge pulse number in an atmospheric helium DBD. By replacing the original sinusoidal applied voltage with a peaklevelled one, the manipulation of current pulse number in each half cycle is achieved. A preliminary analytical method is also proposed to switch the original MCP discharge into a singlecurrent-pulse discharge. In 2021 [123], they tried to use the multi-frequency pulse-type voltage as the control method to control the number of discharge current pulses. The study is carried out numerically with a one-dimensional fluid model. Results show that the number of current pulses in each half cycle decreases from 5 to 1 as shown in Figure 24, indicating the transition from the MCP discharge to single-current-pulse discharge, when the harmonics N increases from 1 to 11. Finally, an analytical method is also presented to estimate the minimum harmonics required to achieve the targeted singlecurrent-pulse discharge.

# 5 | CONCLUSION

In conclusion, various parameters such as gas flow, dielectric material properties, surface conductivities, and electrode shape have significant effects on the appearance of DBD. Gas flow can influence the formation of H-DBD by affecting the density of quenchers and seed electrons within the discharge. Dielectric material properties, such as thickness, surface charge, and shallow traps, can also affect the discharge mode. Surface conductivities and electrode shape are additional parameters that can impact the formation of DBD.

The mechanisms of H-DBD formation were reviewed chronologically. The three-condition hypothesis proposed by



**FIGURE 24** Controlling the number of pulses with different values of the harmonics-related parameter N (a) N = 1, (b) N = 2, (c) N = 5, (d) N = 6, (e) N = 8, and (f) N = 11. Here,  $V_a$  is the applied voltage;  $V_g$  is the gap voltage; J is the discharge current density [123].

Okazaki's group in 1990 was reevaluated and refined by Massines and colleagues in 1998 to be a low breakdown electric field, high residual electron density before ignition of a new discharge, and the use of dielectrics allowing electrons to be trapped in shallow traps of the surface during previous pulses.

The behaviours of N2 metastable species in N2 DBD have been extensively studied. Different hypotheses were proposed to explain the generation of H-DBD in N2. The initial hypothesis of Penning ionisation between two N2 metastable molecules was later challenged due to the short lifetime of N<sub>2</sub>(a), and the addition of Xe to N<sub>2</sub> did not affect the generation of H-DBD. Instead, it was proposed that the flux of  $N_2(A)$  to the dielectric surface, which increases the cathode secondary emission coefficient, is responsible for the generation of seed electrons required for H-DBD. The effect of  $O_2$ concentration on the transition from H-DBD to F-DBD was investigated. It was found that higher O<sub>2</sub> concentrations lead to more effective quenching of N<sub>2</sub>(A) and promote the transition to F-DBD. But this could not explain the observed significant increase in N2 second positive system emission when the  $O_2$  concentration was increased from 0 to 40 ppm. Recently, it was proposed that the associative ionisation reaction between  $N(^{2}P)$  and  $O(^{3}P)$  is responsible for the seed electron. Overall, the understanding of N2 metastable species and their roles in DBD behaviour is still an active area of research, and more studies are needed to fully elucidate the underlying mechanisms. For example, all these cannot explain that H-DBD can also be obtained in the air under certain conditions.

The generation of H-DBD in the air is influenced by various factors, including the electrode structure, dielectric material, and pulse power supplies. Understanding and optimising these factors can help achieve a stable and uniform discharge pattern, which is important for the industrial applications of H-DBD in the air. Further research and development in these areas may lead to improved techniques for generating H-DBD in the air with enhanced performance and efficiency.

Nevertheless, to generate H-DBD, seed electrons are favourable, which can be due to different mechanisms. However, how many roles each mechanism plays is still not clearly understood. Recently, Bajon et al. [124] reported a T-DBD generated in CO<sub>2</sub>, and this is something interesting that might be also helpful for understanding the generation of H-DBD.

The study of multiple-current-pulse (MCP) behaviours in homogeneous dielectric barrier discharges (H-DBDs) has shown that MCPs can occur in atmospheric pressure plasma with different gases, electrode configurations, and applied voltages. Experimental observations and numerical simulations have provided insights into the mechanisms underlying MCP behaviours in H-DBDs. MCPs have been observed at different frequencies of the applied voltage and discharge gap distances and can be related to phenomena such as negative differential resistance of the cathode fall region, radial current distribution, surface charge distribution, and impurity effects. Numerical simulations have been useful in understanding the underlying mechanisms of MCP behaviours, which are difficult to investigate solely through experimental means due to limitations in diagnostics techniques. Overall, the study of MCP behaviours in H-DBDs has contributed to a better understanding of the complex dynamics of atmospheric pressure plasma and can have implications for the design and optimisation of DBD-based plasma devices for various practical applications.

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#### DATA AVAILABILITY STATEMENT

Data sharing not applicable-no new data generated.

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